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Tuning the metal-insulator transition of vanadium dioxide thin films using a stretchable structure

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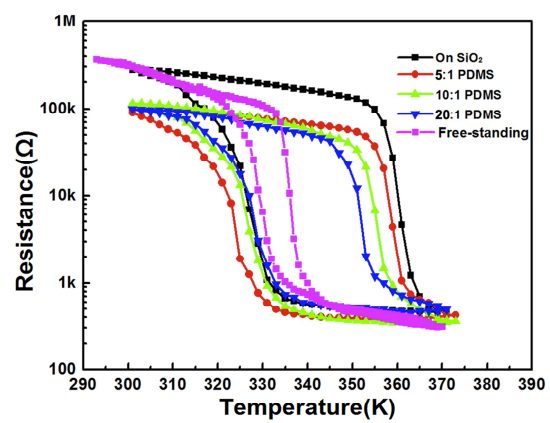
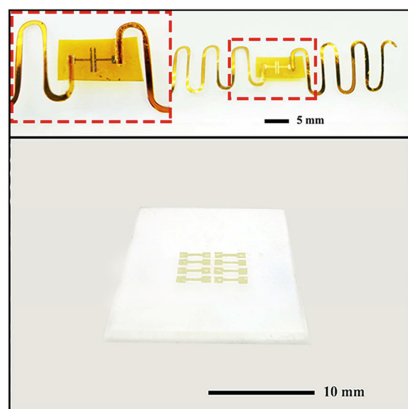
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